

### Dr. Lee Jones Senior Accelerator Physicist

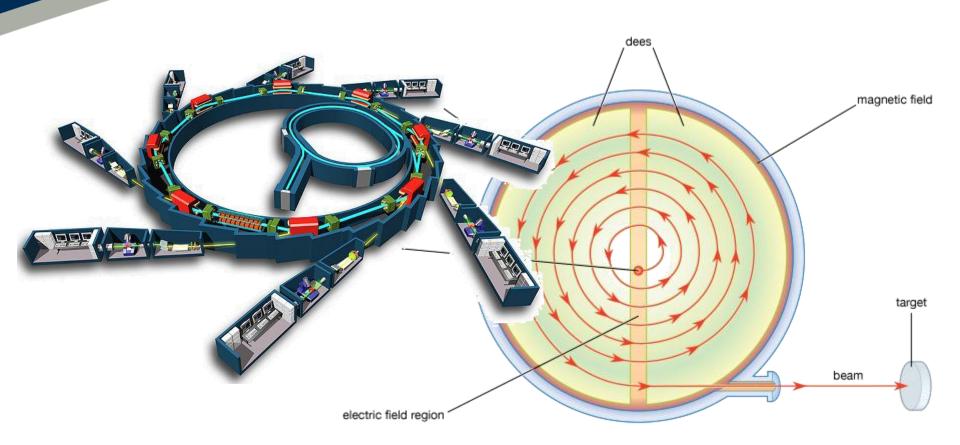
Accelerator Science and Technology Centre STFC Daresbury Laboratory

Photoinjectors: A General Overview





### Over the years ......

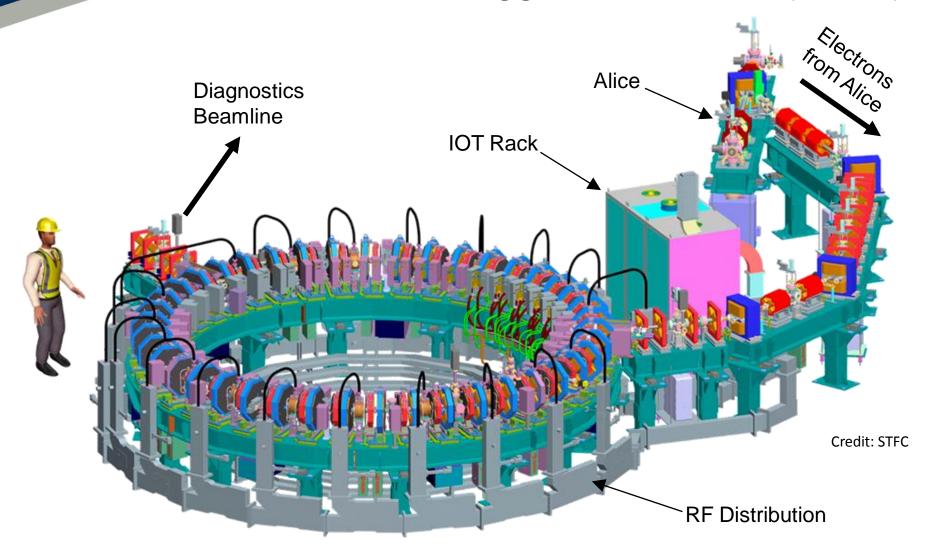


The synchrotron

The cyclotron



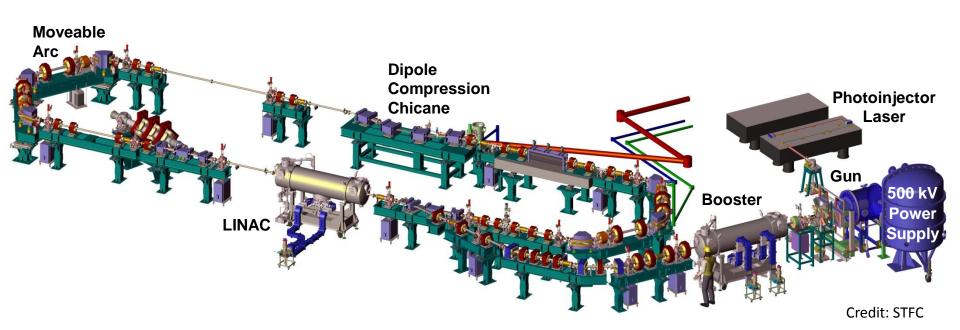
**EMMA**: The world's first non-scaling fixed-field alternating gradient accelerator (nsFFAG)





**ALICE**: Europe's first energy-recovery linear accelerator (ERL)

Single-pass machine → dynamic aperture does not define beam brightness



Nominal Gun Energy: 350 keV Injector Energy: 8.35 MeV Final Beam Energy: 35 MeV

RF Frequency: 1.3 GHz Rep. Rate: 81.25 MHz Bunch Charge: 80 pC Average Current: 6.5 mA

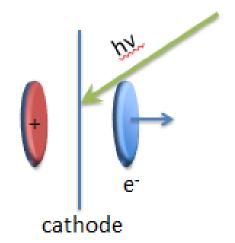


Ultimate beam brightness is now limited by photoinjector performance. Successful FEL operation requires ultra-short high-brightness electron bunches. Key parameters are:

- the photocathode surface electric field ( $E_{cath}$ )
- the Mean Transverse Energy (MTE) of emitted photoelectrons
  - Difficult to measure subject of much research



Joseph Liouville



$$B_{max} = \frac{\epsilon_0 mc^2}{2\pi} \frac{E_{cath}}{MTE}$$

$$\epsilon_{nxy,\text{th}} = \sigma_{xy} \sqrt{\frac{\text{MTE}}{mc^2}}$$

This means that Liouville's theorem applies from the photocathode surface



- What is a an electron gun?
  - Combines electron source with beam conditioning and a high voltage for acceleration
- Possible electron gun technologies:
  - Hot filament
  - Angelestron gun? ..... No

### A high-performance electron machine gun!!!

- Plasmonic surfaces & structures
- Photoinjector
  - Photocathode
  - Illumination by pulsed laser
  - Emittance compensation + accelerating stage(s)

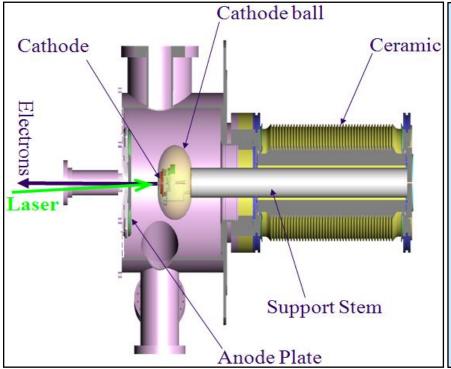


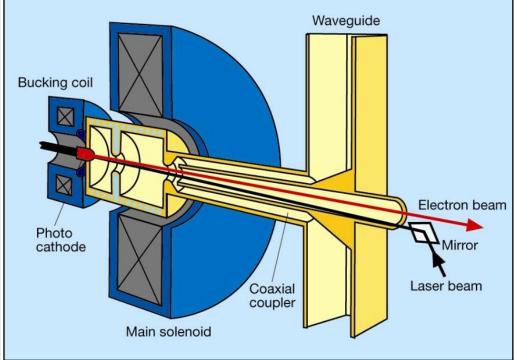
Two general classes of photocathode electron sources have evolved to meet this challenge:

These differ primarily in terms of

- Cost DC / RF / SRF
- Repetition rate

DC Gun RF Gun







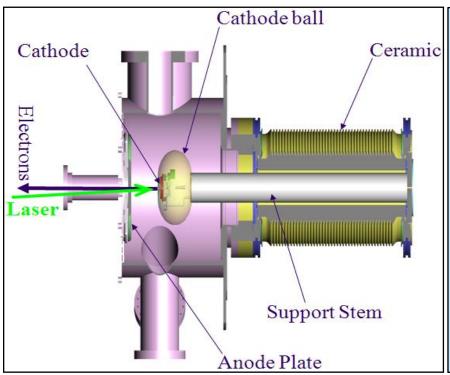
### DC/RF Gun performance FOM:

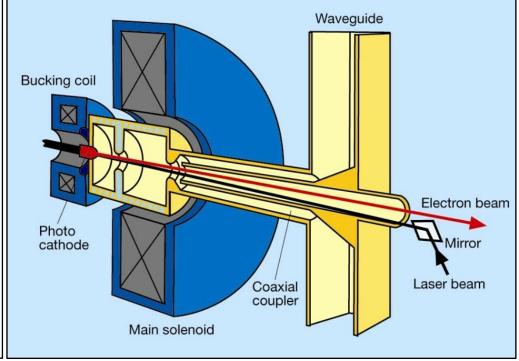
$\varepsilon_{n,rms} =$	1	$2qE_i$
	$\frac{1}{2}$	$\overline{3\pi\varepsilon_0E_{cath}mc^2}$

q = bunch charge [C]

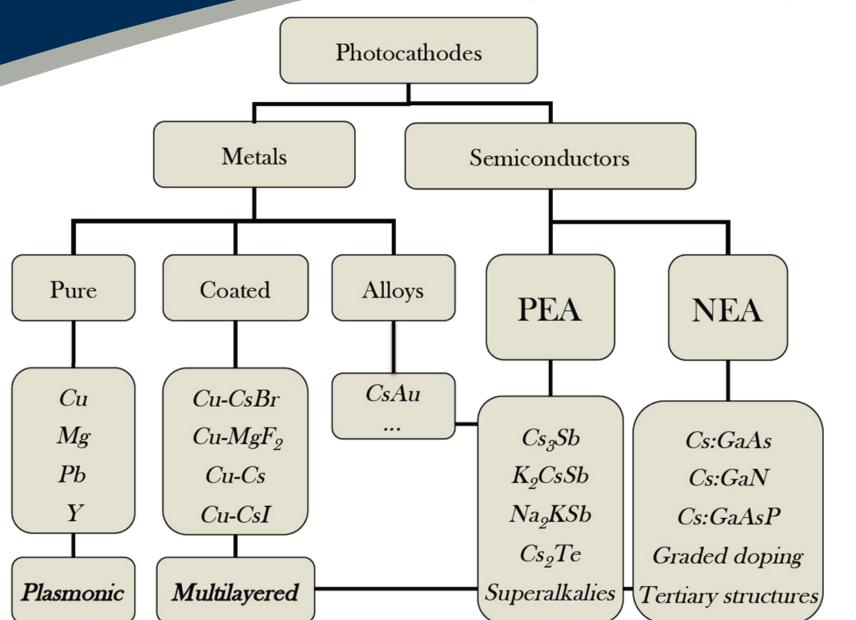
 $E_i$  = initial energy [eV]

Field strength, $E_{cath}$	Technology	0.01 nC	0.1 nC	1.0 nC
10 MV/m	DC gun	0.11	0.34	1.08
20 MV/m	VHF gun	0.08	0.24	0.77
50 MV/m	L-band gun	0.05	0.15	0.48
100 MV/m	S-band gun	0.03	0.11	0.34





### The photocathode family tree





#### DC Guns: Technical challenges

- Power supply ripple
- Vacuum requirements dependent on cathode
- Back-ion bombardment
- Dark current / field emission
- HV Conditioning use of He/Kr during processing
- Insulating ceramic electrical and mechanical loading



# DC Guns: Technical challenges Power supply ripple

PSU ripple drives fluctuations in beam emittance, bunch shape, bunch arrival time, and average energy after full acceleration.

Phase change at a distance L away from the gun caused by gun voltage variation:

$$\Delta \varphi = 2\pi f \frac{L}{c} \frac{\gamma - 1}{(\gamma \beta)^3} \frac{\Delta V_{gun}}{V_{gun}}$$

where  $\varphi$  is in radians, f is the RF frequency, c is the speed of light, and  $\Delta V_{gun}/V_{gun}$  is relative ripple of the gun voltage.

In terms of RF phase, variations of  $\pm$  1° are tolerable for low emittance beams.

At 1.3 GHz,  $\pm$  1° in phase is approximately  $\pm$  2 ps in arrival time, corresponding to a shift of  $\pm$  450 V (0.18%) 1 metre from a 250 kV gun.

The voltage ripple needs to be specified over the **frequency ranges present in the power supply**, typically up to 60 kHz (or more) for switching power supplies.



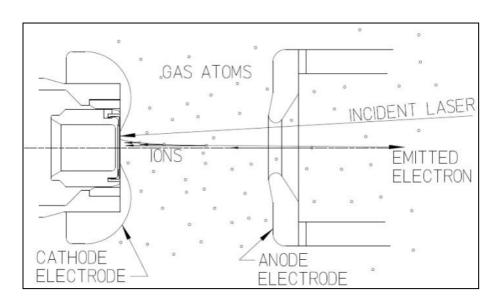
### DC Guns: Technical challenges Vacuum considerations

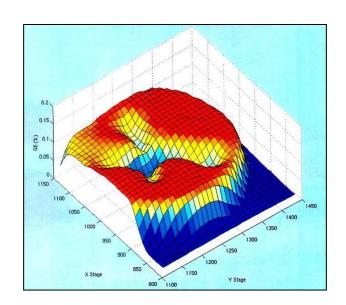
- Much easier to pump a DC gun chamber than an RF gun
- Photocathodes used in a DC gun generally have very high vacuum requirements
  - Requires use of high-quality materials and good engineering practices
  - Pumping to XHV achieved through use of large ion pumps and NEG coatings,
     and baking for a long time
- Vacuum degraded by gun operations, and in-situ photocathode preparation
  - Maintenance of good gun vacuum requires an external photocathode preparation facility (PPF)
- Poor vacuum leads to contamination of the photocathode, and thereby a drop in the Quantum Efficiency (*Q.E.*)
- Poor vacuum also increases the back-ion bombardment rate, reducing photocathode lifetime and the maximum achievable Q.E.



### DC Guns: Technical challenges **Back-ion bombardment**

- Back-ion bombardment is a major challenge in DC guns
- It degrades Q.E. and damages the cathode surface
- Reduced by good vacuum, but fundamentally un-avoidable
- Worst effects occur within a few mm of the photocathode surface
- Positive bias on the anode suppresses back-ions from downstream





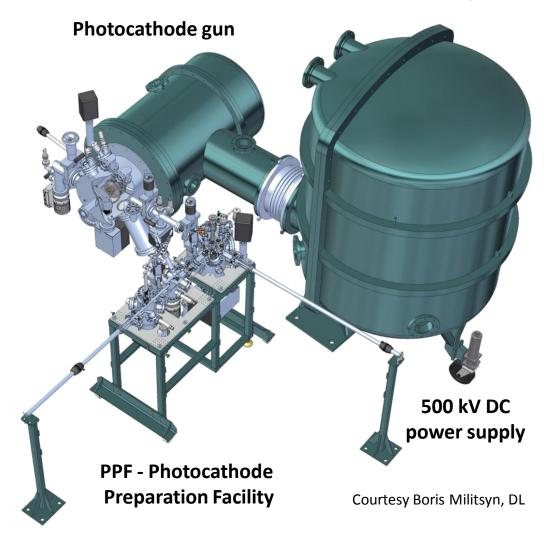
Courtesy Joe Grames, JLab



### The use of a PPF confers several operational advantages:

- Improved environment for photocathode activation
- Reduced accelerator down-time for photocathode activation, permitting operations with high bunch charge
- Improved gun operating environment
  - Better gun vacuum
  - Reduces contamination of the gun HV electrodes
- Permits accelerator operation with different types of photocathodes

#### DC Guns: Technical challenges



Photocathode Preparation Facility for the ALICE ERL DC photocathode gun



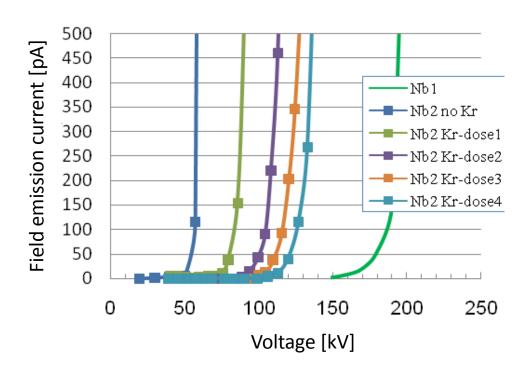
### DC Guns: Technical challenges

### High voltage conditioning

- Potentially dangerous, but essential for stable operation of a DC gun
- HV electrodes must be 'trained' to support high voltages
- Conditioning necessary to desired operating voltage + 10% as a minimum
- Use of Kr during HV conditioning is beneficial for new HV electrodes

**Right:** Measurements of field emission between two single crystal niobium electrodes, polished with BCP process and HV conditioned using Kr.

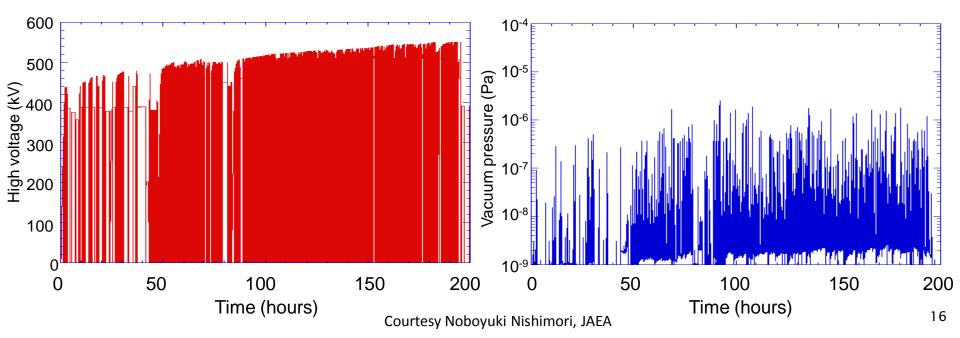
Courtesy Matt Poelker, JLab





# DC Guns: Technical challenges **High voltage conditioning**

- Potentially dangerous, but essential for stable operation of a DC gun
- HV electrodes must be 'trained' to support high voltages
- Conditioning necessary to desired operating voltage + 10 % as a minimum
- Use of Kr during HV conditioning is beneficial for new HV electrodes
- Can be very time-consuming

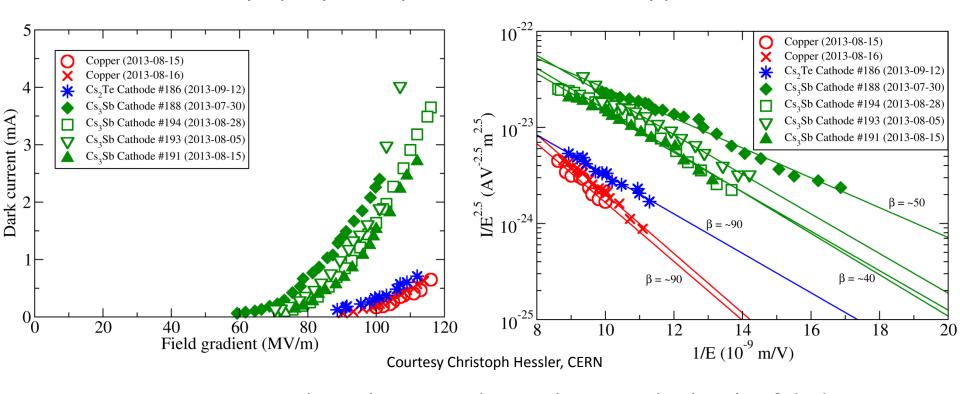




#### DC Guns: Technical challenges

#### **Dark current & Field emission**

- Some dark current is un-avoidable in any photocathode gun
  - Intrinsic property of the photocathode, affected by photocathode choice



Measurements show that Cu and Cs<sub>2</sub>Te have similar levels of dark current emission, but Cs<sub>3</sub>Sb exhibits much higher dark current levels.



#### DC Guns: Technical challenges

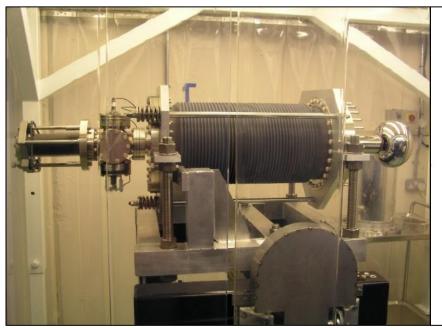
#### **Dark current & Field emission**

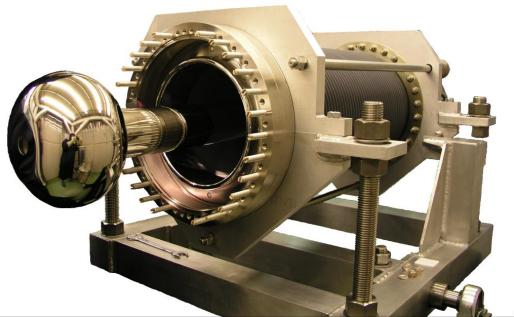
- Some dark current is un-avoidable in any photocathode gun
  - Intrinsic property of the photocathode, affected by photocathode choice
- Low-level field emission is also unavoidable, but must be managed
  - Careful design of HV surfaces and maximum electric field strength
  - Clean conditions during assembly
  - Effective HV conditioning
- Intense or sudden field emission can be catastrophic
  - Tracking along ceramic short circuit
  - Punch-through causing a leak
- Biased (floating) anode plate permits dark current measurements



# DC Guns: Technical challenges Insulating ceramic

- Insulating ceramic must withstand extreme DC voltage and a large mechanical load whilst maintaining large pressure difference
- It should not be a perfect insulator !!!
- Surface coating or bulk doping for high resistivity



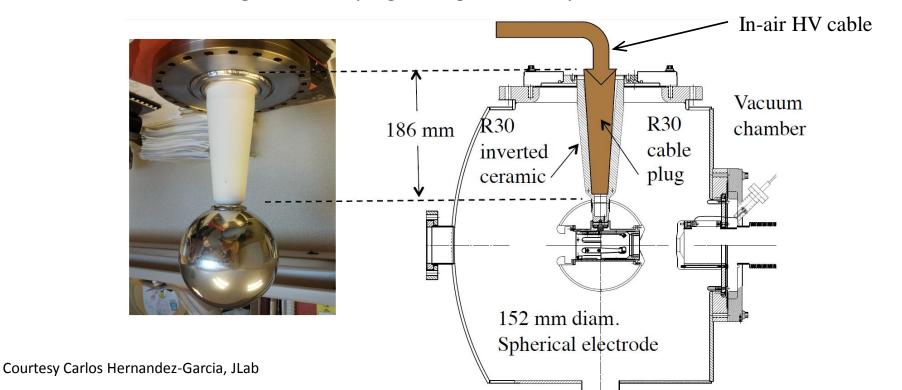




# DC Guns: Technical challenges Insulating ceramic

20

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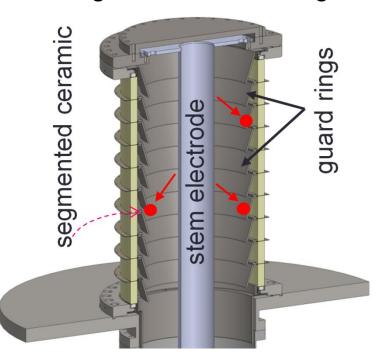




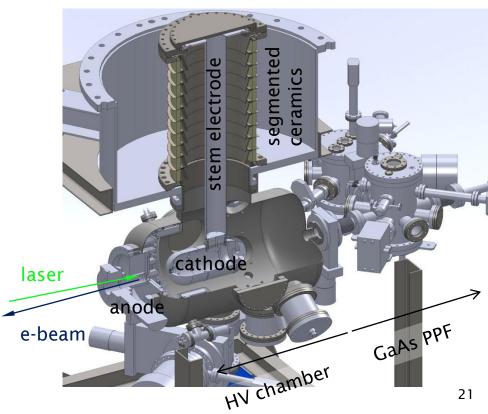
### DC Guns: Technical challenges **Insulating ceramic**

- Insulating ceramic must withstand extreme DC voltage and a large mechanical load whilst maintaining large pressure difference
- It should not be a perfect insulator !!!

Segmented ceramic with guard rings



500 kV Photocathode gun at JAEA





# RF Guns: Technical challenges **Some common ground**

RF guns share some of the technical challenges described for DC guns:

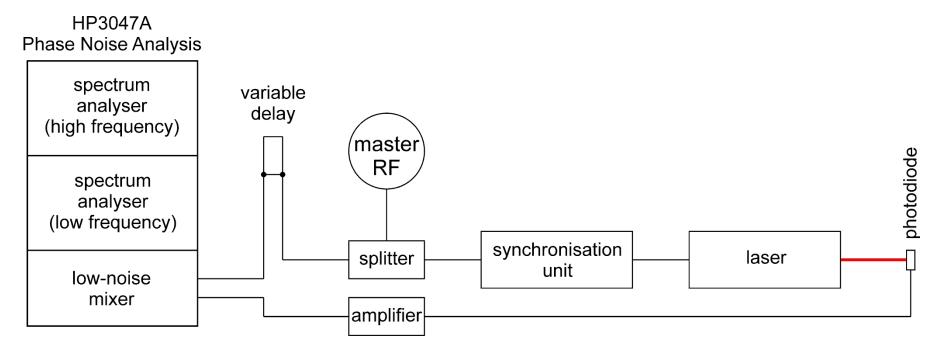
- Photocathode integration
  - Vacuum environment & electric field disruption
  - Different photocathode 'standards'
  - Collaborations difficult vacuum suitcases needed
- DC Ripple / effective RF ripple amplitude and timing
  - Cavity temperature stability
- Symmetric and uniform electric field
- Dark current / field emission
- Synchronisation of the photoinjector drive laser to the RF via a master clock
  - Use of optical clocks for distributed timing Holgar Schlarb, DESY
  - Problems increase with the size of the facility



- Arguably the most critical factor in a photocathode/photoinjector gun
- Very difficult to measure accurately !!!
  - Amplitude noise indistinguishable from phase noise
- Best-practice for phase noise measurements in lasers establish by Scott et. al: IEEE J. Sel. Top. Quan. Elec.; 7(4), 641, 2001

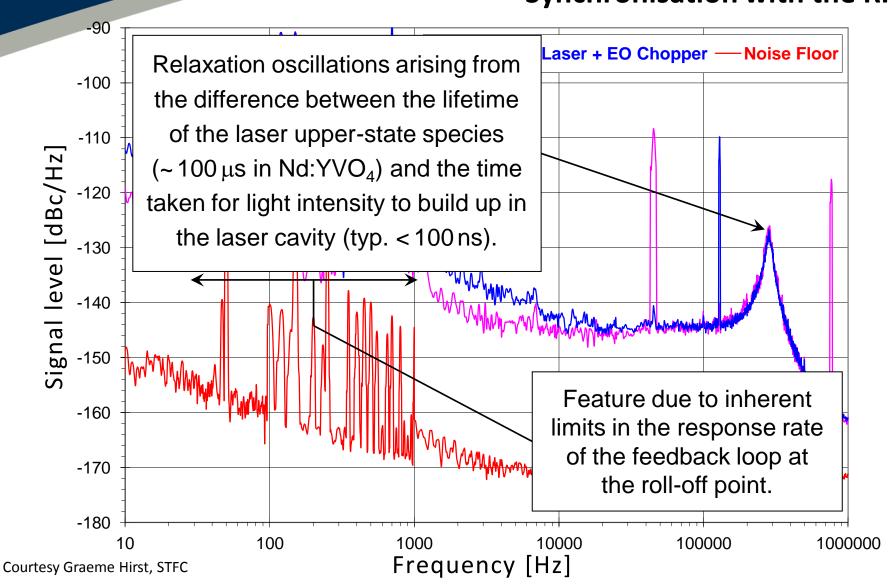


**Measurements on ALICE**: Initially, the noise floor of the HP3047A system was measured by feeding the same signal from a *Wenzel* low-noise 81.25 MHz RF oscillator into both inputs of the low-noise mixer in quadrature. The laser was then synchronised to the oscillator, and the laser output fed back to a low-noise mixer via a fast photodiode.

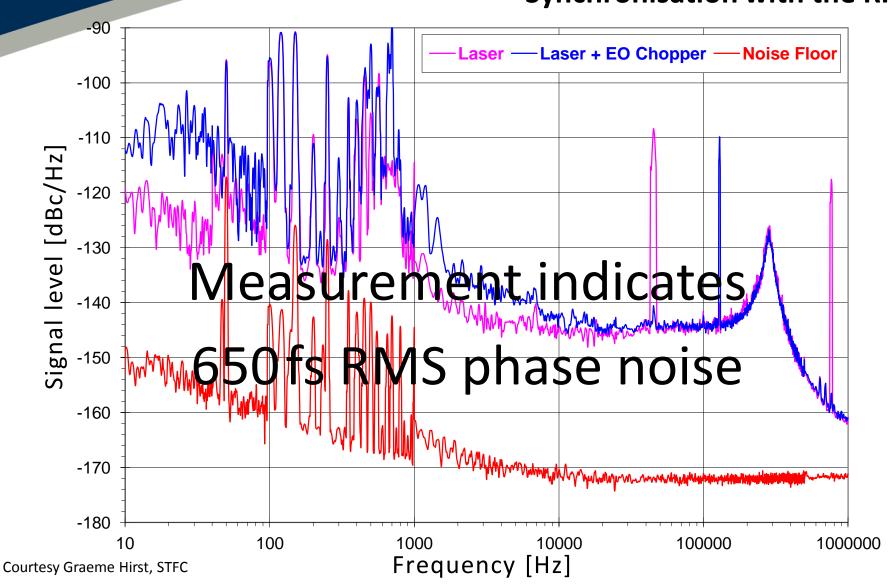


Courtesy Graeme Hirst, STFC





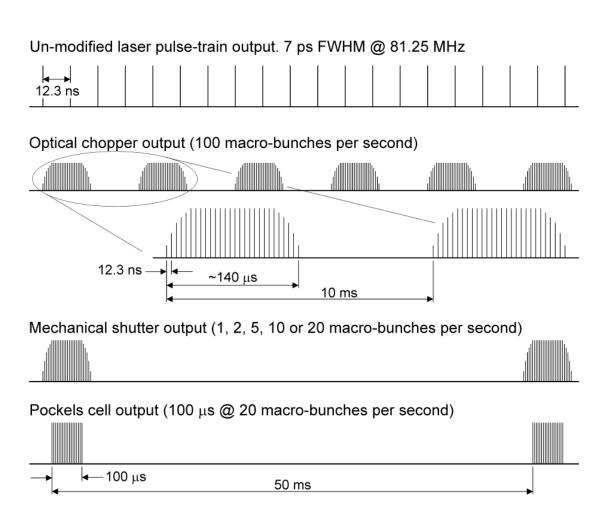






### DC & RF Guns: Drive Lasers Extinction ratio

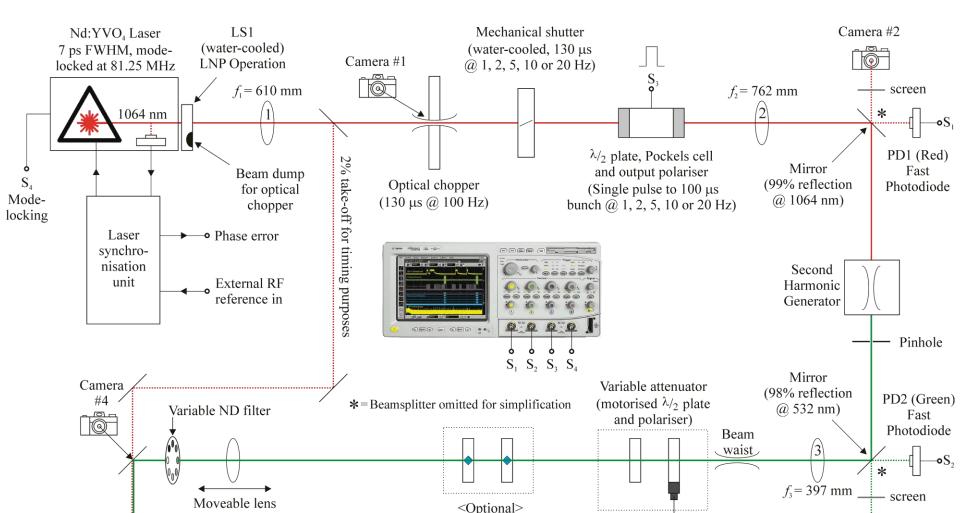
#### Extinction ratio is *critical* in a non-CW machine





### DC & RF Guns: Drive Lasers Extinction ratio

#### Pulse chopping carried out at long $\lambda s$ , then frequency $2\omega$ or $3\omega$ applied

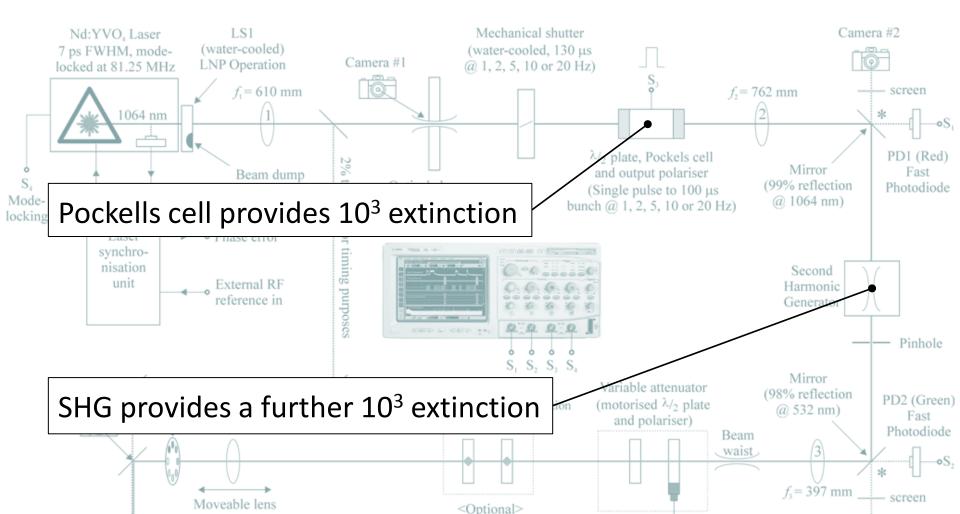




### DC & RF Guns: Drive Lasers

#### **Extinction ratio**

Pulse chopping carried out at long  $\lambda s$ , then frequency  $2\omega$  or  $3\omega$  applied

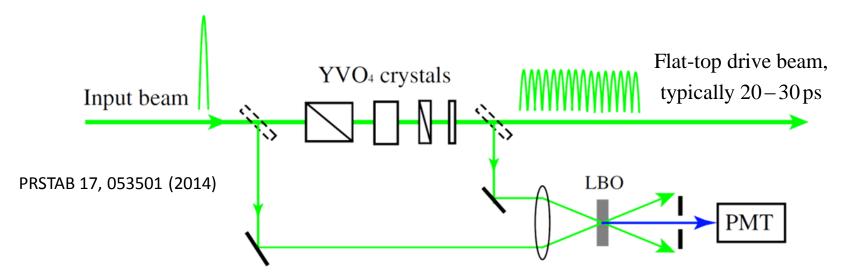




#### DC & RF Guns: Drive Lasers

#### **Longitudinal & transverse shaping**

- The 3D intensity distribution of the laser determines the 3D distribution of the photoemitted electrons
- The initial electron distribution has a significant effect on emittance in a space-charge-dominated beam
- Longitudinal and transverse laser spatial profiling can minimise emittance



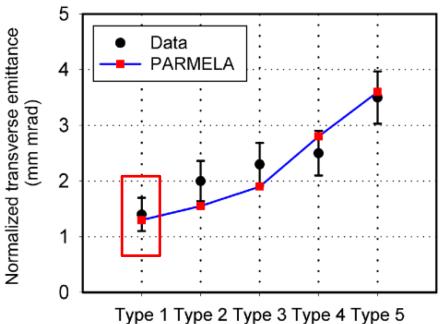
- Four YVO<sub>4</sub> crystals used in series to 'stack' copies of the incoming short laser pulse
- Cross-correlation measurement used to monitor overall pulse length

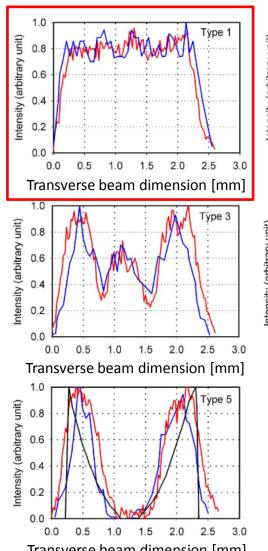


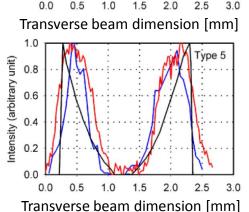
### DC & RF Guns: Drive Lasers **Longitudinal & transverse shaping**

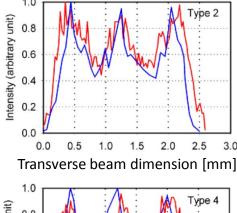
A non-uniform laser beam generates a nonuniform electron beam which expands at a rate linked to the plasma period.

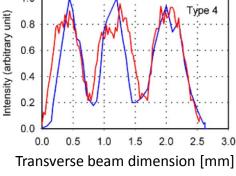
The best electron beam is achieved with a truncated Gaussian transverse laser beam.











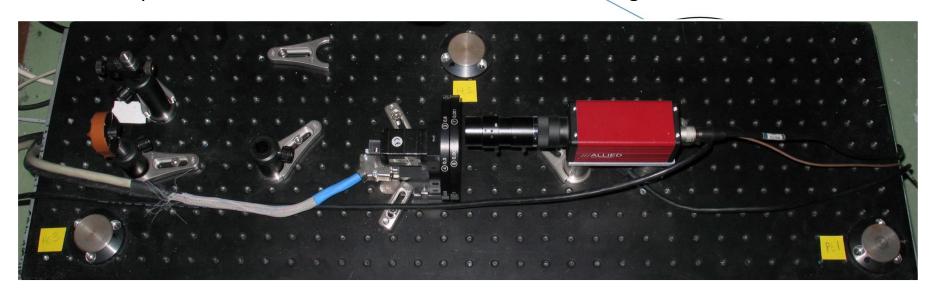
Emittance tests on various transverse laser beam profiles

PRSTAB 5, 094203 (2002)



# DC & RF Guns: Drive Lasers Good practice

- Off-centre illumination to avoid worst effects of back-ion bombardment
  - Cornell claim no detriment to emittance for a 0 4 mm laser offset
- Use of a virtual cathode
  - Concept inspired by DESY Zeuthen
  - o Splits off small fraction of drive laser beam and images this on a screen



# The Cornell 1.3 GHz, 1 ps rod fibre amplifier photoinjector drive laser

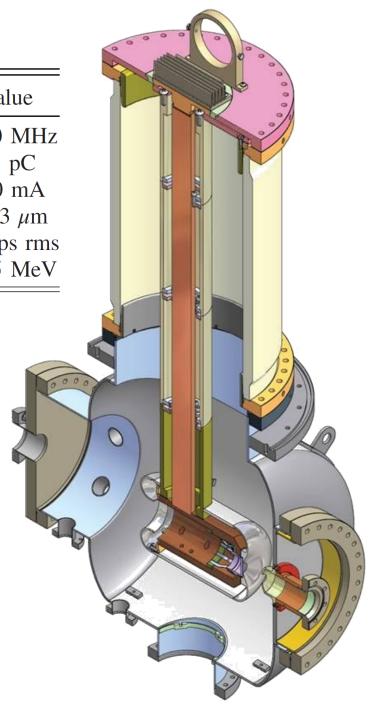
- 167 W IR laser power at 1.3 GHz (fibre amplifier)
- 124 W green laser power at 1.3 GHz
- 800 fs micropulses, stretchable to 80 ps 'stacked'
- Further power increases possible

"Enabling next-generation high-current X-ray sources"

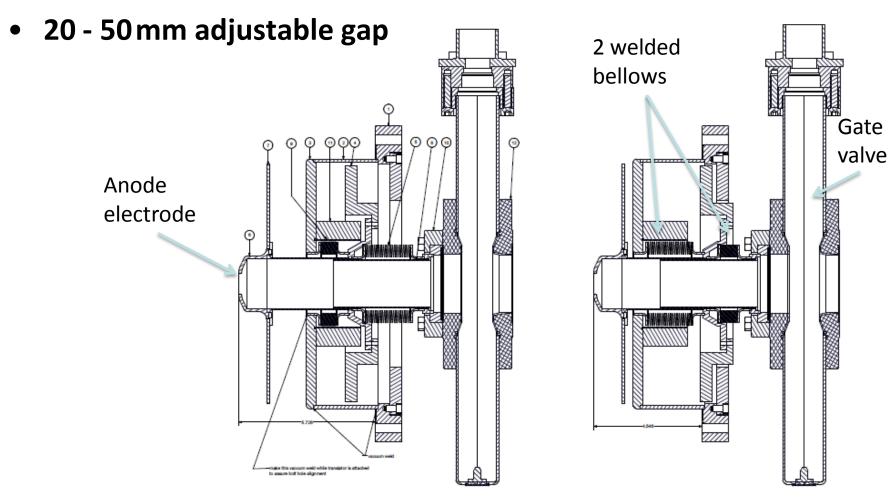
### The Cornell ERL Injector – DC Gun

Parameter	Value
Frequency	1300 MHz
Charge per bunch	77 pC
Average current	100 mA
Normalized emittance	≤0.3 µm
Bunch duration	2–3 ps rms
Beam energy	4–15 MeV

- Demonstrated high-current operations at 65 mA using a Na<sub>2</sub>KSb photocathode (2.6 day lifetime)
- Brief operation at 75 mA World Record
- Low emittance beams (near thermal threshold)
- Extremely high DC voltages are not necessary



- Gun originally designed for 750 kV operation
- Cathode field is crucial
- Translatable anode to tailor the cathode field strength



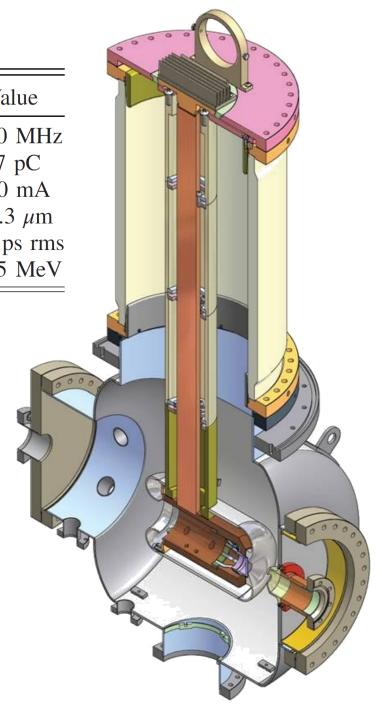
Small gap, 20 mm

Large gap, 50 mm

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- Brief operation at 75 mA World Record
- Low emittance beams (near thermal threshold)
- Extremely high DC voltages are not necessary
- Simulations + optimisations match experiments
- Halo/beam loss can be maintained below
   1 part in 10<sup>7</sup> to 10<sup>8</sup>
- Photocathodes are still the key challenge





### Thank you for listening ©

Credits to colleagues for material used in this presentation:

Dr. Bruce Dunham, Cornell Dr. Graeme Hirst, STFC (ret)

Dr. Joe Grames, JLab Dr. Boris Militsyn, STFC

Dr. Carlos Hernandez-Garcia, JLab Dr. Noboyuki Nishimori, JAEA

Dr. Christoph Hessler, CERN Dr. Matt Poelker, JLab

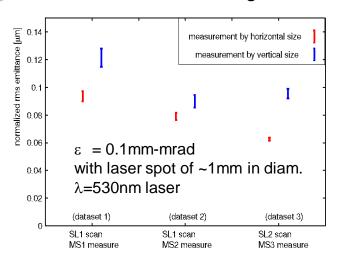


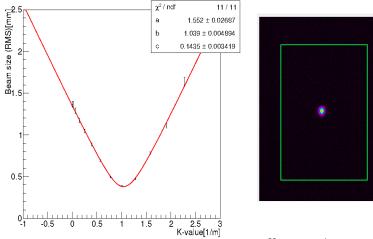


### Preliminary emittance measurements

Y. Honda, T. Miyajima, et al., "Transverse Beam Performance Measurement at compact-ERL Injector", 10<sup>th</sup> Meeting of Particle Accelerator Society of Japan, SUP011, (2013).

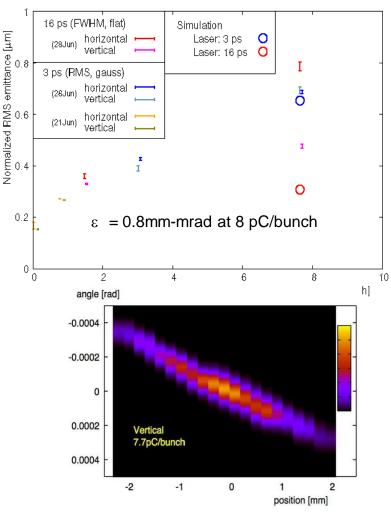
#### Thermal emittance at the gun at E=390keV





#### ut Jefferson Lab Beam profile on YAG screen

#### Emittance at the injector at E=5MeV



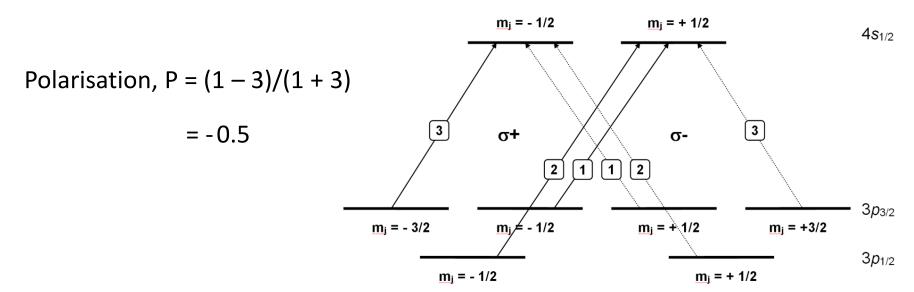
Phase space distribution measured with a slit scan



#### DC Guns: Drive Lasers

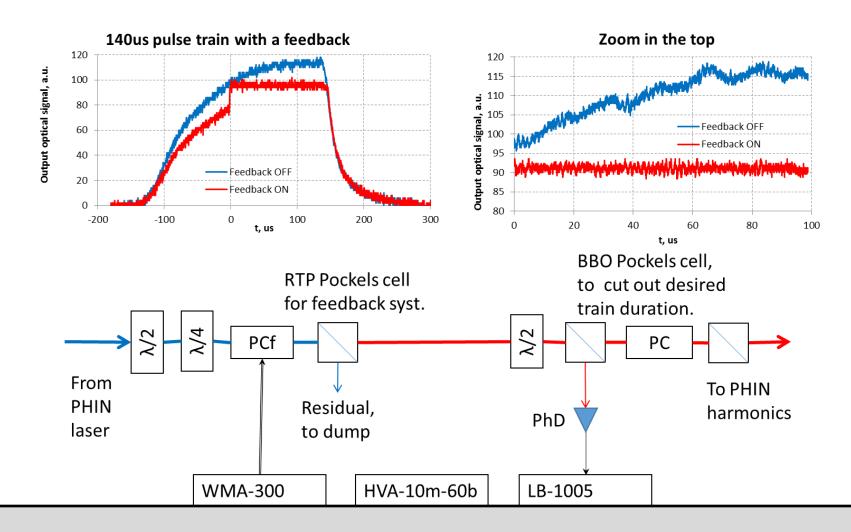
#### **Polarised electrons**

- Polarised emission from the  $4s_{1/2}$  band when illuminating GaAs (100)
- $\lambda \sim 800 \,\text{nm}$  RCP generates  $\Delta m_i = +1$  and LCP generates  $\Delta m_i = -1$
- Clebsch-Gordan coefficients give likelihood of transition
- Transitions from  $m_i = -3/2$  state 3 times more likely than those from  $m_i = -1/2$  state





### Feedback Stabilization



Result: Improvement of intensity stability (laser beam) and charge stability (electron beam) by a factor of 3 down to 0.4% rms and 1% rms